

2172
#4

I hereby certify that this correspondence is being deposited with the U.S. Postal Service with sufficient postage as First Class Mail, in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on the date shown below.

Dated: April 8, 2004

Signature: _____

(Jonathan A. David)

Docket No.: INSTAK 3.0-001
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Pramod Khandekar

Application No.: 09/714,903

Group Art Unit: 2172

Filed: November 16, 2000

Examiner: Corrielus, Jean M.

For: METHOD AND SYSTEM OF DEPLOYING
SERVER-BASED APPLICATIONS

RECEIVED

APR 13 2004

Technology Center 2100

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

This communication is in response to the Office Action mailed March 23, 2004, setting forth a Restriction Requirement in the above-identified application. In the Office Action, the Examiner required restriction to one of the following inventions under 35 U.S.C. § 121:

I. Claims 1-14, drawn to a server computing environment for generating web page information, classified in class 707, subclass 10.

II. Claims 15-16, drawn to determine the best shipping cost quote using custom criteria, classified in class 705, subclass 13, 37, 52 and 402.

In response, Applicant hereby elects the invention of Group II, corresponding to claims 15-16. Applicant reserves the right to file a divisional application corresponding to the non-elected claims.




Application No.: 09/714,903

Docket No.: INSTAK 3.0-001

In the event any fee is due in connection with the present response, the Examiner is authorized to charge Applicant's Deposit Account No. 12-1095 therefor.

Dated: April 8, 2004

Respectfully submitted,

By 
Jonathan A. David

Registration No.: 36,494
LERNER, DAVID, LITTENBERG,
KRUMHOLZ & MENTLIK, LLP
600 South Avenue West
Westfield, New Jersey 07090

(908) 654-5000
Attorney for Applicant

LD-469\486849_1

RECEIVED

APR 13 2004

Technology Center 2100